



Results from HPK 35 & 50 μm UFSD

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- Comparison HPK 35 & 50 μm LGAD
- Doping Profile of 50 μm HPK LGAD
- Inter-pad gap



Comparison HPK 35 μm and 50 μm LGAD



50 μm thick LGAD (HPK 50D)

Single pad (1.3 mm² area)

capacitance 2.7 pF

For HGTD pad area= 1.7 mm² expect $C(50 \mu\text{m}) = 3.4 \text{ pF}$

Z. Galloway et al., arXiv: 1707.04961

Comparing with

35 μm thick LGAD (HPK sample "B")

Single pad (1.3 mm² area)

capacitance 4.6 pF

For HGTD pad area= 1.7 mm² expect $C(35 \mu\text{m}) = 4.8 \text{ pF}$

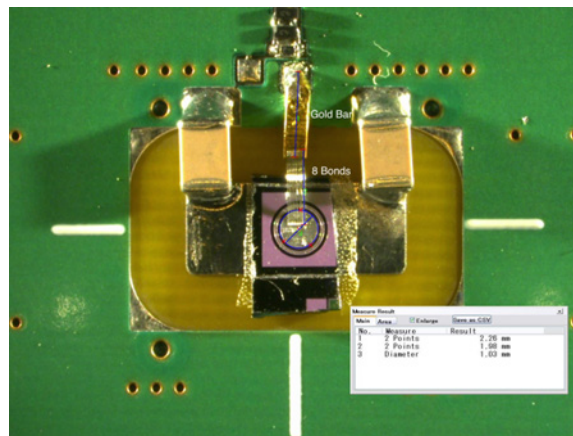
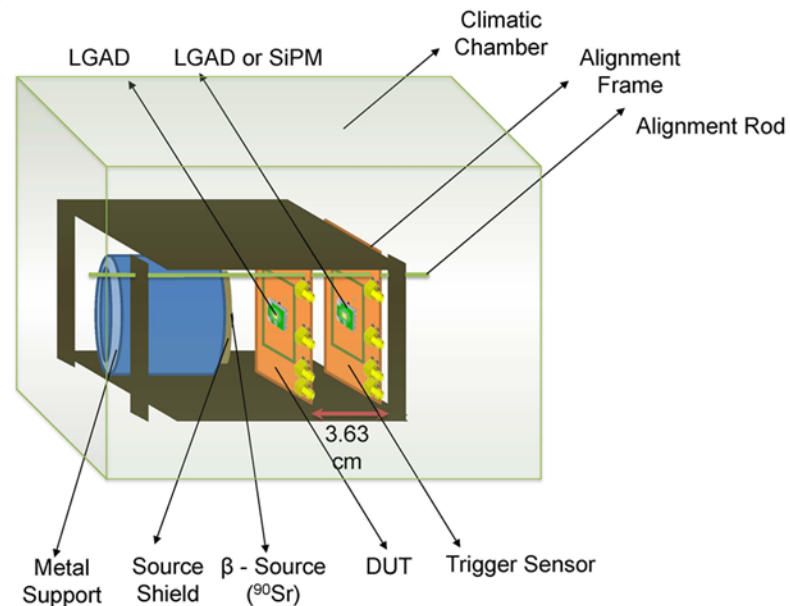
Measured in the β -telescope Pre-rad and post-rad $1\text{e}15 \text{ n/cm}^2$, -20° C

^{90}Sr β -source Set-up:

DUT LGAD between source and trigger plane

Trigger: either known LGAD or quartz/SiPM

Climate chamber allows operation between -30C and +20C



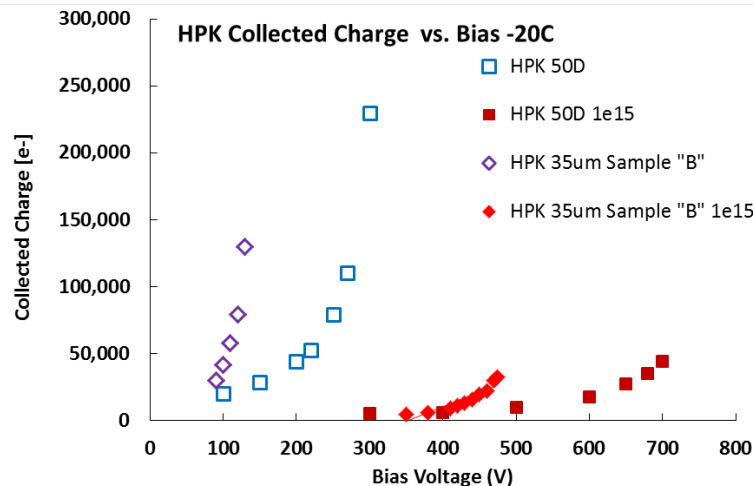
Measurement of pulse shapes with amplifier board (Low-noise, fast $\sim 3\text{GHz}$) developed at UCSC, now available from CERN



Bias Dependence of Coll. Charge, Gain & Pmax

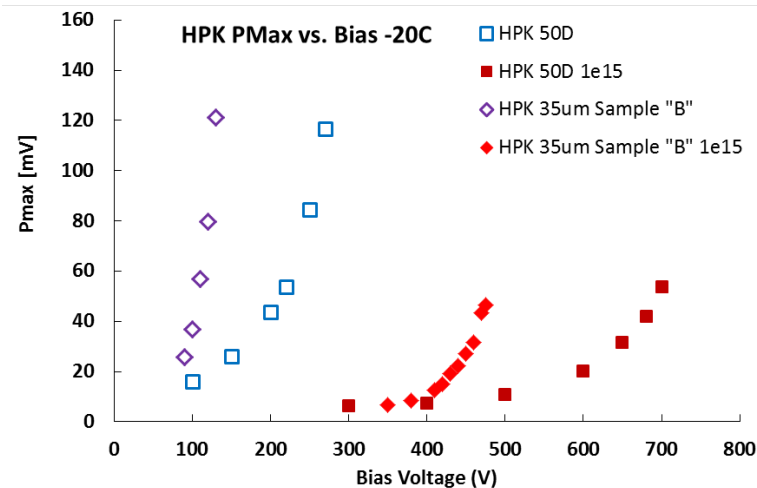
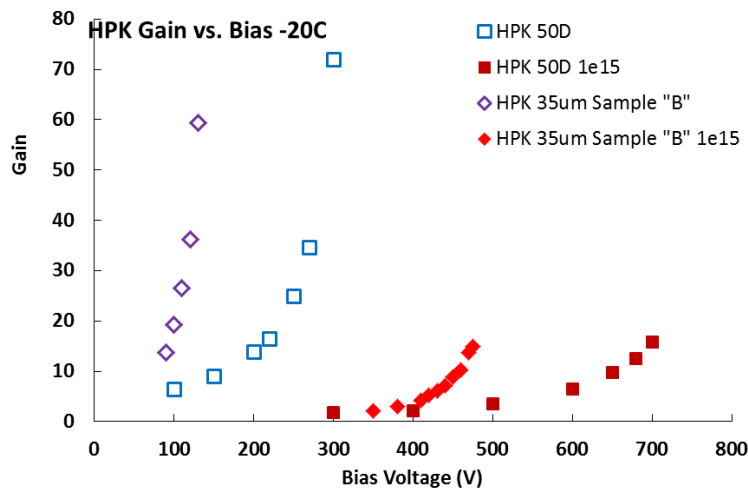


Hartmut F.-W. Sadrozinski, "HPK 35 μ m & 50 μ m UFSD"

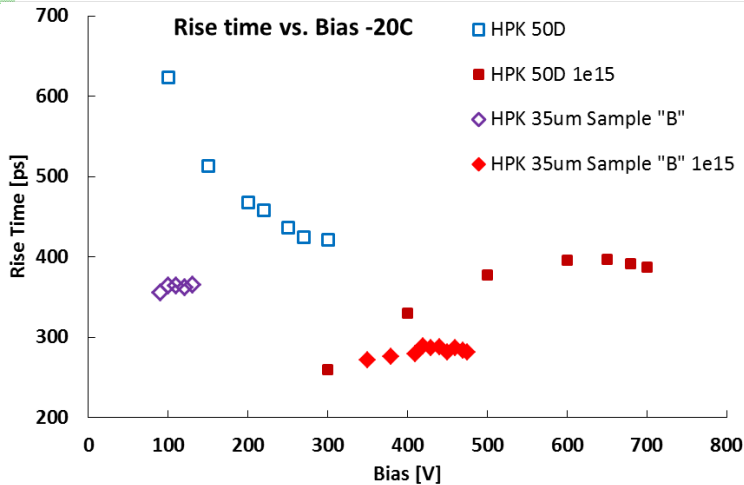


Post-rad performance similar
BUT
Lower bias voltage for 35 μ m!

Bias voltage gap of ~ 200 V is
preserved through radiation.



Rise time (10% - 90%) and Noise



Rise Time

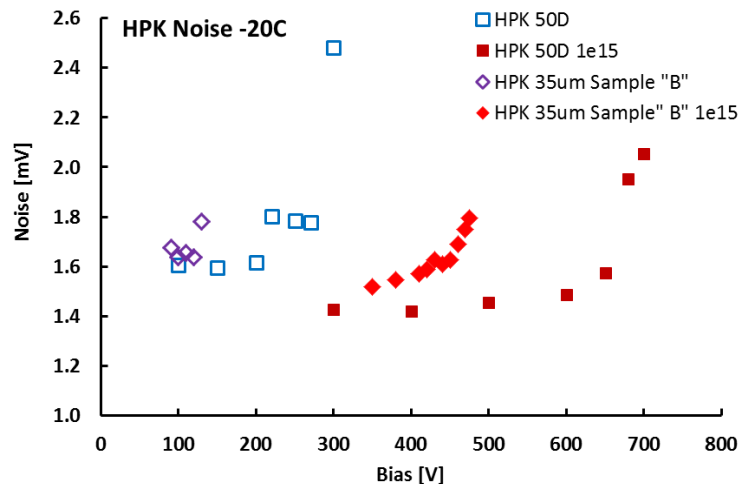
Before radiation:

- 363 ps (35 μm) vs. 422 ps (50 μm)

After 1e15 n/cm²

- 281 ps (35 μm) vs. 387 ps (50 μm)

(Lower post-rad values explain the good post-rad performance)

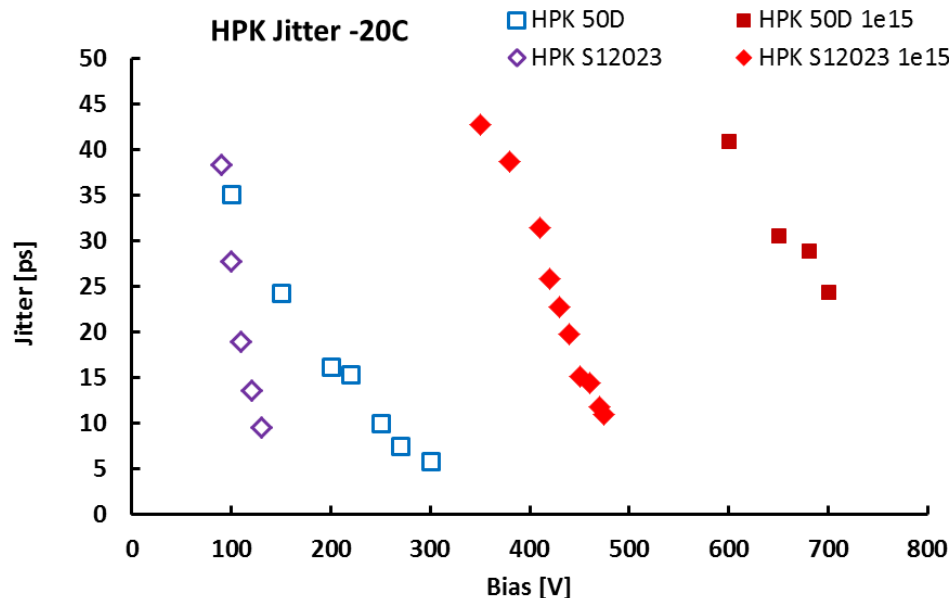


Noise

Increase of noise at large bias voltage (even before radiation for 50 μm) .

Large noise and increased rise time at large bias explain the relatively large jitter for 50 μm post-rad

Jitter vs. Bias and Pmax



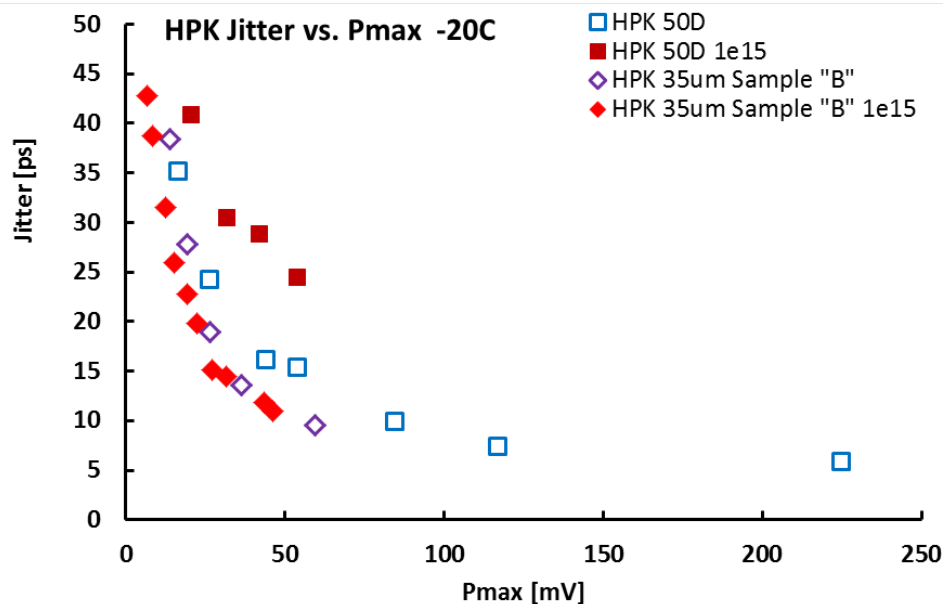
$$\sigma_t^2 = \sigma_{TimeWalk}^2 + \sigma_{LandauNoise}^2 + \sigma_{Distortion}^2 + \sigma_{Jitter}^2 + \sigma_{TDC}^2$$

$$\sigma_{TimeWalk} = \left[\frac{V_{th}}{S/t_{rise}} \right]_{RMS} \propto \left[\frac{N}{dV} \right]_{RMS}$$

$$\sigma_{Jitter} = \frac{N}{dV/dt} \approx \frac{t_{rise}}{S/N}$$

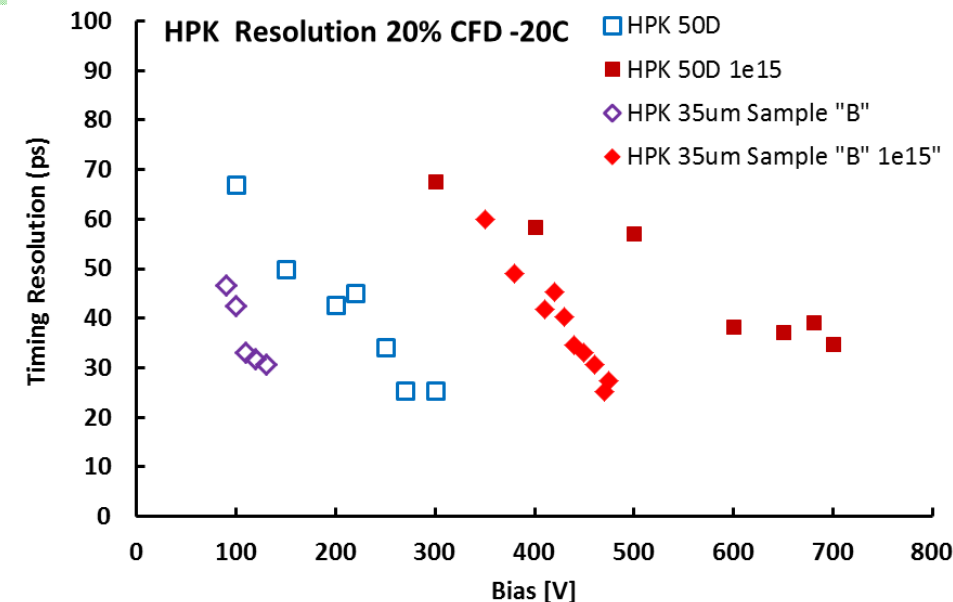
Jitter

Clear advantage of 35 μm wrt 50 μm





Timing resolution vs. Bias and Coll. Charge



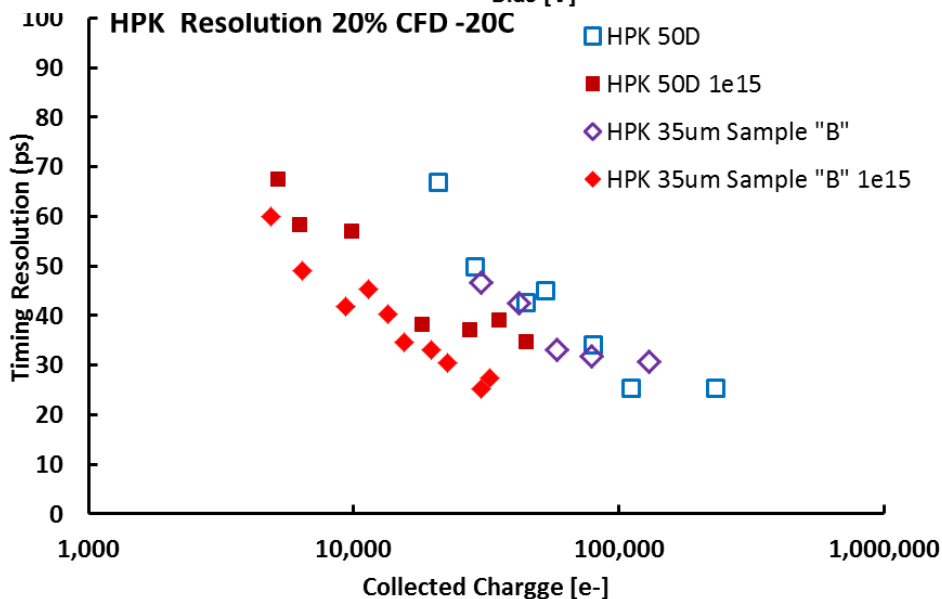
Time Resolution (CFD 20%)

Before radiation:

- 30 ps (35 μm) vs. 25 ps (50 μm)

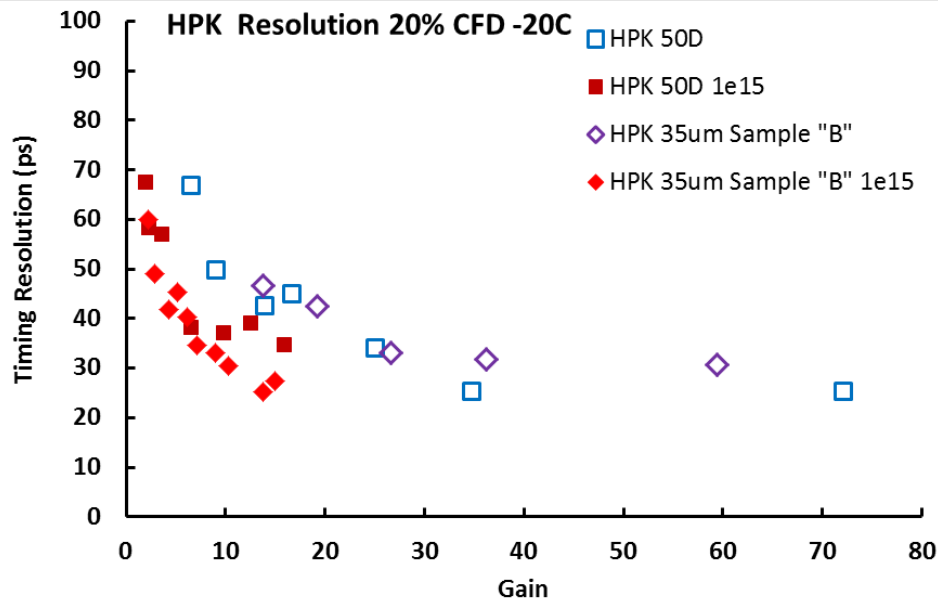
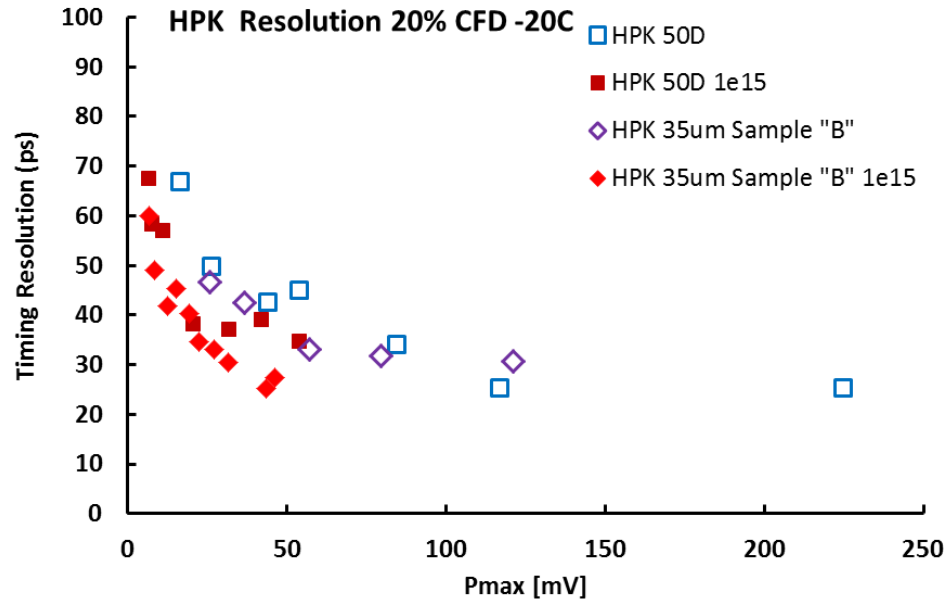
After 1e15 n/cm²

- 25 ps (35 μm) vs. 35 ps (50 μm)



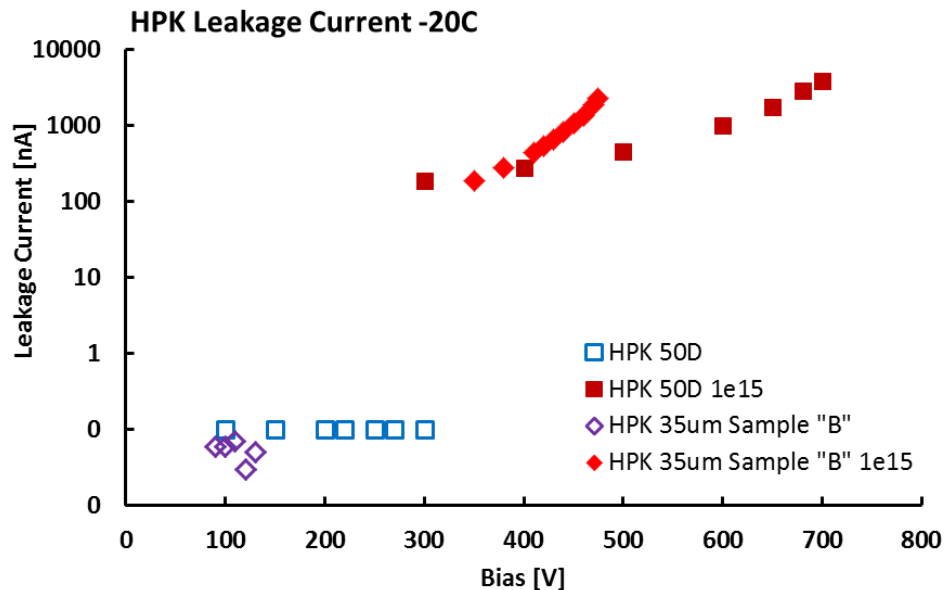


Timing resolution vs. Pmax and Gain





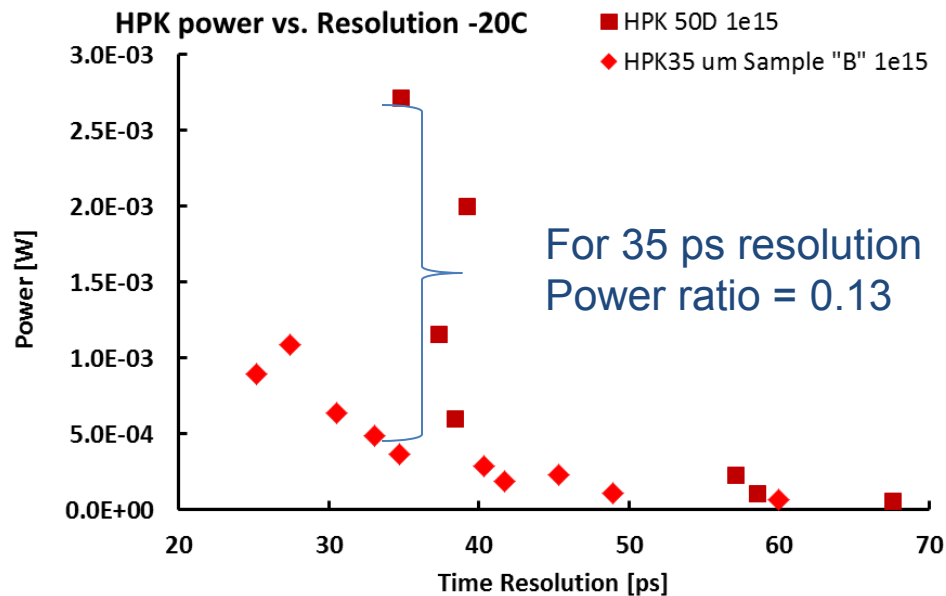
Leakage Current & Power vs. Timing resolution



Power Consumption:

Lower current, lower bias
-> lower power

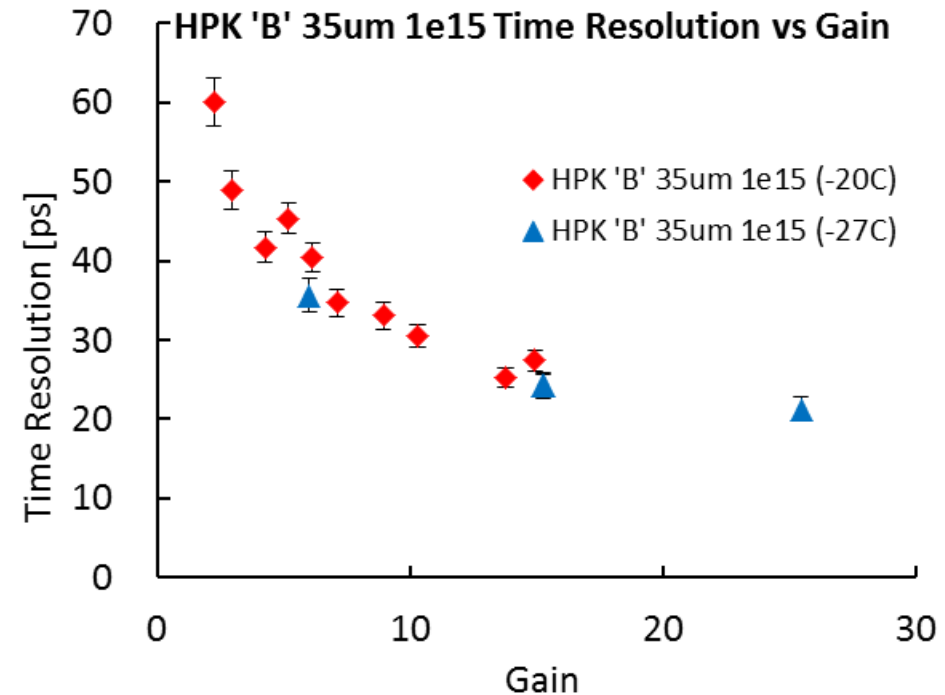
Comparison of power
for same time resolution



Effect of Temperature: Time Resolution



New data with HPK "B" 35 μm
Compare operation at -20C and -27C



Overall Improvement with 50 μm \rightarrow 35 μm LGAD thickness:

(Fluence 1e15 n/cm²)

HPK 50D $\sigma_t = 35$ ps (-20C)

HPK "B" $\sigma_t = 25$ ps (-20C)

HPK "B" $\sigma_t = 21$ ps (-27C) (40% improvement)

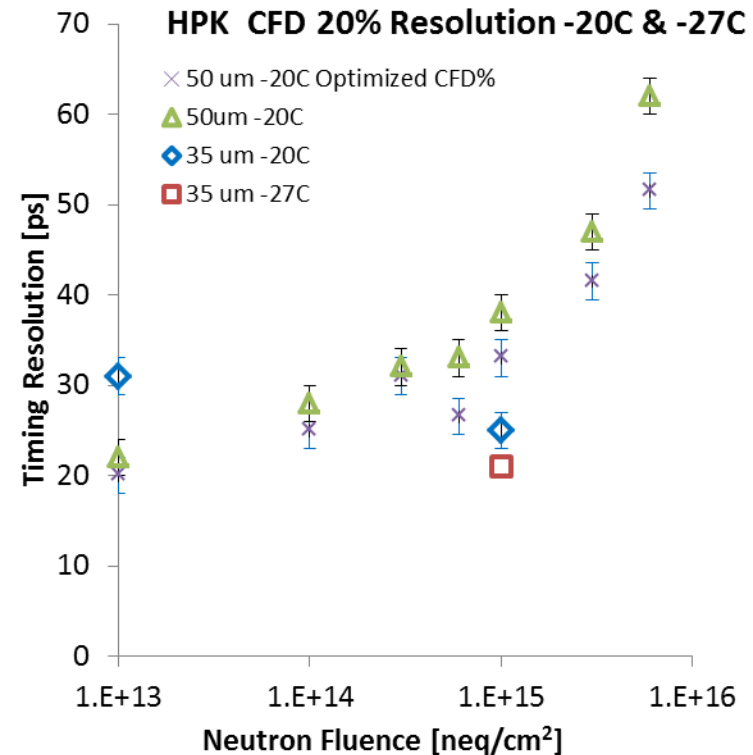
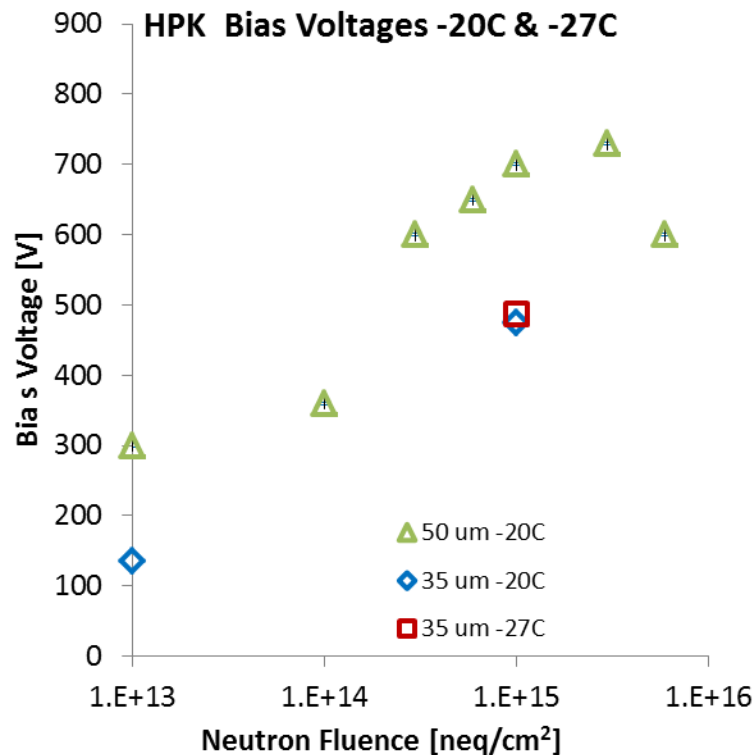
N.B. Advantage of lower temperature in reaching high gain \rightarrow better resolution



Score card 50 μm vs. 35 μm



HPK "B" 35 μm :
Lower bias voltage, better resolution



N.B. use CFD 20% resolution, which for 50 μm is worse than the one with optimized CFD fraction.



Summary on LGAD Thickness



Measure in β -telescope two LGAD from HPK with thickness 35 μm and 50 μm .

Pre-rad both sensors have similar performance

30 ps (35 μm) vs. 25 ps (50 μm) @ -20C
(35 μm has low bias voltage)

After $1\text{e}15 \text{ n/cm}^2$:

35 μm sensor superior to 50 μm sensor due to lower rise time and lower bias:

Superior time resolution:

25 ps (35 μm) vs. 35 ps (50 μm) @ -20C

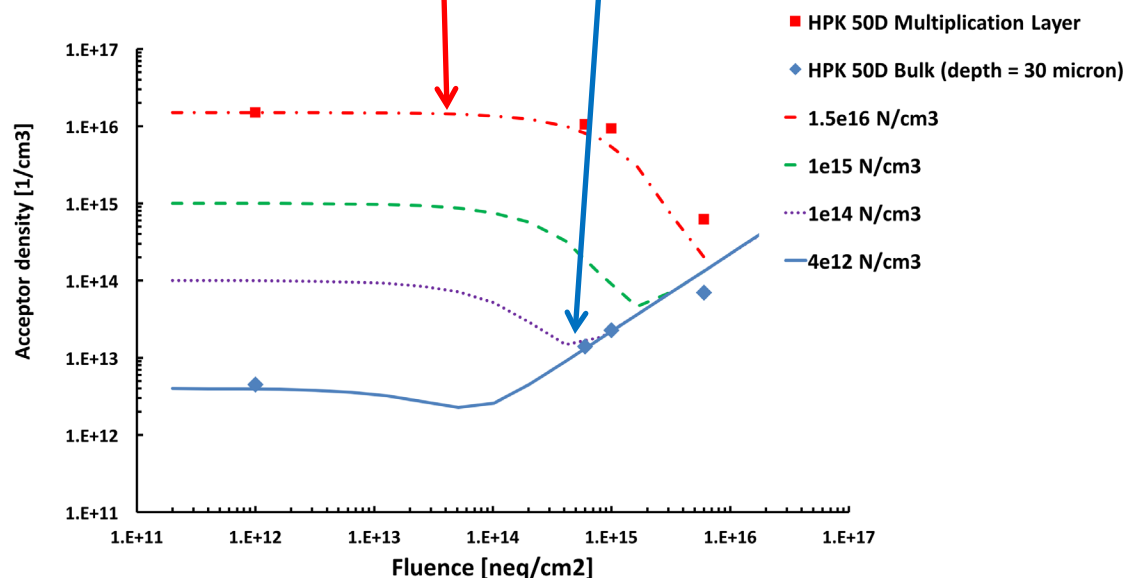
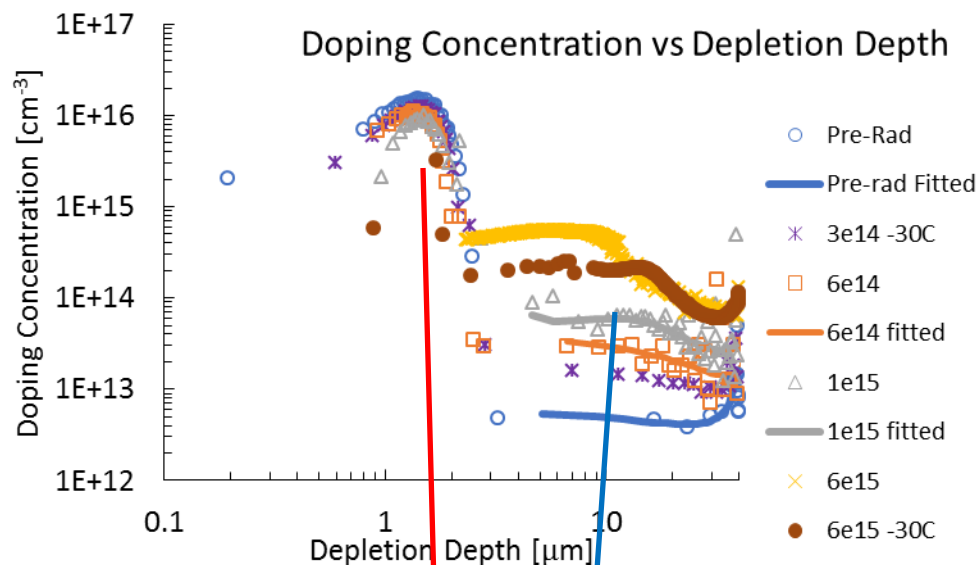
21 ps (35 μm) @ -27C

Reduced bias voltage : 500 V (35 μm) vs. 700 V (50 μm)

Reduced power



Acceptor Dynamics: neutrons



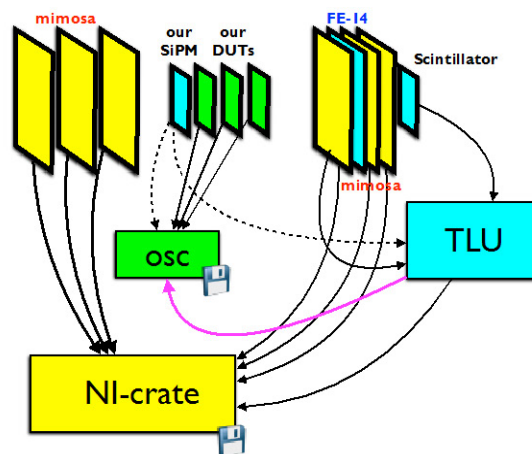
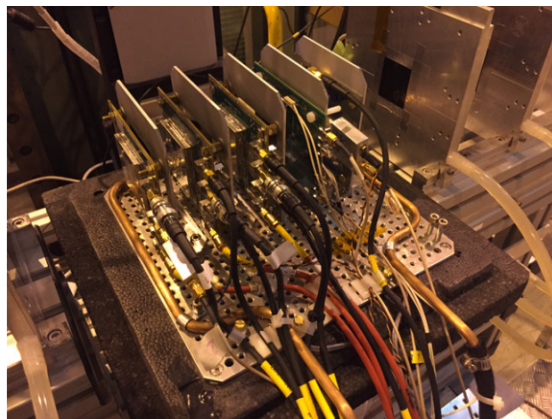
For HPK 50 μm 50D LGAD
Neutron fluence: 0-6e15 n/ cm^2

C-V at -20C (200Hz)
Measure simultaneously
acceptor **removal** and **creation**.
Annealed for ~ 2hrs at +60C,

Thin sensor minimizes
interference from “double-
junction”.

Clear agreement with the
acceptor removal/creation
picture.

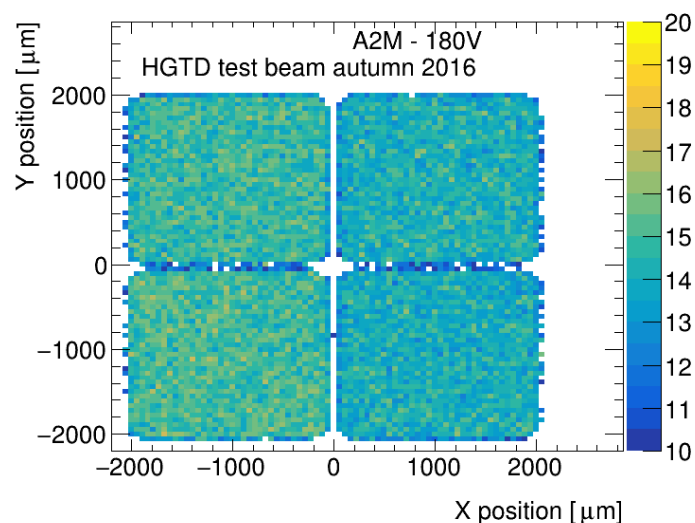
Looking forward for surprises
with proton data



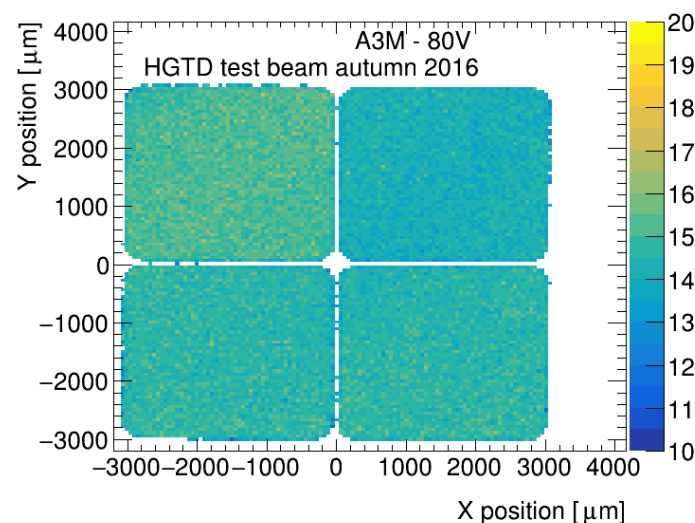
Fill-factor =
Active area / geometrical area
depends on inter-pad gap

Gain and occupancy maps show inter-pad gap

W7 HG22

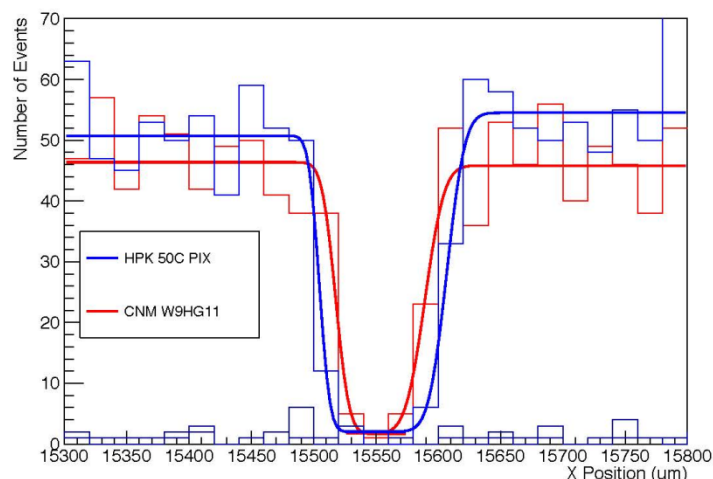


W8 HG11



Fill-Factor: Inter-pad gap

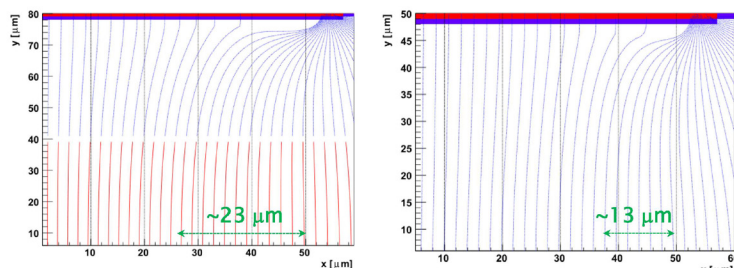
Occupancy Profile in X



Fill-factor depends on manufacturer:
Occupancy scan of two 2x2 array of 3x3 mm^2 pads showing different width of the inter-pad gap:
CNM (red) : 70 μm
HPK (blue) : 100 μm

Patrick Freeman, UCSC MS Thesis

Effect of device thickness



5 μm JTE with 10^{15} cm^{-3}
3 μm p⁺ with 10^{16} cm^{-3}
80 μm thick detector

5 μm JTE with 10^{15} cm^{-3}
3 μm p⁺ with 10^{16} cm^{-3}
50 μm thick detector

Around 10 μm difference in "active area" according to the drift paths better for 50 μm detector

Gap increases with detector thickness as expected.



Fill-factor depends on LGAD thickness:
TCAD simulations of field lines show the inter-pad gap depending on the LGAD thickness

G. Kramberger

<https://indico.cern.ch/event/672871/contributions/2752995/attachments/1557256/2449555/EdgeSimulation-HGTD-Nov2017.pdf>

What about thinner sensors (35 μm)?



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This work was supported by the United States Department of Energy, grant DE-FG02-04ER41286.

Part of this work has been financed by the European Union's Horizon 2020 Research and Innovation funding program, under Grant Agreement no. 654168 (AIDA-2020) and Grant Agreement no. 669529 (ERC UFSD669529), and by the Italian Ministero degli Affari Esteri and INFN Gruppo V.

This work was partially performed within the CERN RD50 collaboration.



Back-up



Hartmut F.-W. Sadrozinski, "HPK 35 μm & 50 μm UFSD"

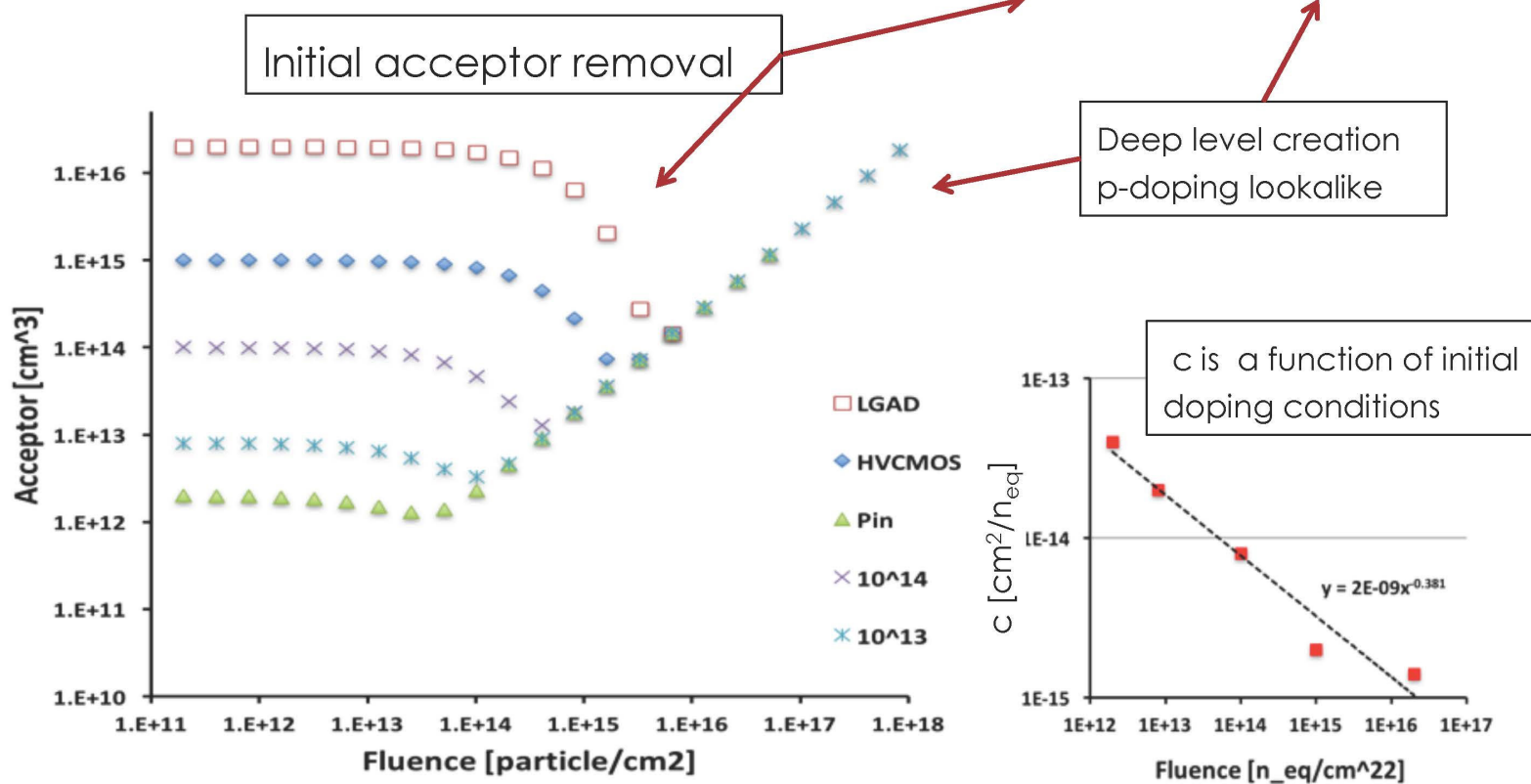


Acceptor Dynamics: neutrons

Initial acceptor (Boron) removal

Density of the boron doping vs irradiation:

$$N_D = N_0 e^{-c\phi} + \beta\phi$$



New data with HPK "B" 35 μ m
Compare operation at -20C and -27C



N.B. Advantage of lower temperature in reaching high gain \rightarrow better resolution